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(54) Title: PROCESS FOR PRODUCING ENANTIOPURE β -AMINO ACID DERIVATIVES, AND ENANTIOPURE β -AMINO ACID DERIVATIVES

(57) Abstract: Process for producing enantiopure β -amino acid derivatives corresponding to general formula (I) R1-NZ-CHR2-CH2-COOR3 (I) in which R1 and R2 independently denote organic residues optionally forming a cyclic substituent, R3 denotes H or an organic residue, and Z represents H or an amino function-protecting group, comprising a step in which a mixture of enantiomers of a compound corresponding to general formula (II) R1-NZ-CHR2-CH2-COOR4 (II) in which R1, R2 and Z are as defined for formula (I), and R4 is an organic residue, is subjected to hydrolysis in the presence of a lipase.

WO 2004/087940 A2



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